AMENDMENT UNDER 37 C.F.R. § 1.111 Attorney Docket No.: Q95891

Application No.: 10/586,149

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the

application:

LISTING OF CLAIMS:

1-21. (canceled).

22. (previously presented): An n-channel or ambipolar field-effect transistor

including an organic semiconductive layer having an electron affinity EA_{semicond}; and an organic

gate dielectric layer forming an interface with the semiconductive layer; characterised in that the

bulk concentration of trapping groups in the gate dielectric layer is less than 10¹⁸cm⁻³, where a

trapping group is a group having (i) an electron affinity EA_x greater than or equal to EA_{semicond}

and/or (ii) a reactive electron affinity EA_{rxn} greater than or equal to (EA_{semicond.}-2eV).

23. (previously presented): A transistor according to claim 22, wherein the transistor

is an ambipolar field-effect transistor.

24. (previously presented): A transistor according to claim 22 wherein EA_{semicond.} is

greater than or equal to 2eV.

25. (previously presented): A transistor according to claim 24 wherein EA_{semicond.} is in

the range of from 2eV to 4eV.

26. (previously presented): A transistor according to claim 22 wherein the gate

dielectric layer comprises an organic insulating material and the organic insulating material does

not contain a repeat unit or residue unit comprising a trapping group.

27. (previously presented): A transistor according to claim 22, wherein the insulating

material does not contain a repeat unit or residue unit comprising a group having (i) an electron

affinity EA_x greater than or equal to 3eV and/or (ii) a reactive electron affinity EA_{rxn} greater than

or equal to 0.5eV.

28. (previously presented): A transistor according to claim 27 wherein the insulating

material does not contain a repeat unit or residue unit comprising a quinone, aromatic -OH,

aliphatic -COOH, aromatic -SH, or aromatic -COOH group.

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29. (previously presented): A transistor according to claim 22, wherein the insulating material contains one or more groups selected from alkene, alkylene, cycloalkene, cycloalkylene, siloxane, ether oxygen, alkyl, cycloalkyl, phenyl, and phenylene groups.

- 30. (previously presented): A transistor according to claim 22 wherein the insulating material comprises an insulating polymer.
- 31. (previously presented): A transistor according to claim 30, wherein the insulating polymer is selected from the group consisting of substituted and unsubstituted poly(siloxanes) and copolymers thereof; substituted and unsubstituted poly(alkenes) and copolymers thereof; substituted and unsubstituted poly(styrenes) and copolymers thereof; and substituted and unsubstituted poly(oxyalkylenes) and copolymers thereof.
- 32. (previously presented): A transistor according to claim 31, wherein the backbone of the insulating polymer comprises a repeat unit comprising $-Si(R)_2$ -O-Si(R)₂- where each R independently is methyl or substituted or unsubstituted phenyl.
- 33. (previously presented): A transistor according to claim 30, wherein the insulating polymer is crosslinked.
- 34. (previously presented): A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive polymer.
- 35. (previously presented): A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive oligomer.
- 36. (previously presented): A transistor according to claim 22 wherein the organic semiconductive layer comprises a semiconductive small molecule.
 - 37. (previously presented): A method for making a transistor as defined in claim 22.
- 38. (previously presented): Use of a transistor according to claim 22 for n-channel conduction in an n-channel or ambipolar field effect transistor.
- 39. (previously presented): Use of an organic gate insulating material that does not contain any chemical groups having (i) EA_X greater than or equal to 3eV and/or (ii) EA_{rxn} greater than or equal to 0.5eV, for n-channel conduction.

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40. (previously presented): Use according to claim 39, wherein the insulating material does not contain any chemical groups having (i)EA_X greater than or equal to 2eV and/or (EA_{rxn}) greater than or equal to 0eV.

- 41. (previously presented): A circuit, complementary circuit, or logic circuit including a transistor as defined in claim 22.
- 42. (previously presented): A method for making a circuit, complementary circuit, or logic circuit as defined in claim 41.